

Notice of References Cited		Application No. 09 920689	Applicant(s) <i>ANDERSON et al</i>
		Examiner <i>M. C. Zay</i>	Group Art Unit 16/6
		Page <u>7</u>	

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*	DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS
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* A copy of this reference is not being furnished with this Office action.
(See Manual of Patent Examining Procedure, Section 707.05(a).)

INFORMATION DISCLOSURE CITATION	Atty. Docket No.: 56240US003		Serial No.: 09/920,689
	Applicant(s): ANDERSON et al.		
	Filing Date: August 2, 2001	Group: 1615	

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EXAMINER	Date Considered
<i>Melley</i>	<i>12/10/02</i>

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